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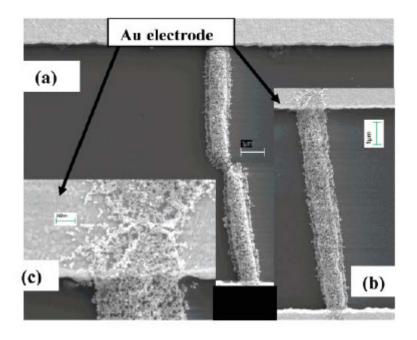
Highly Selective, Electrically Conductive Monolayer of Nanoparticles on Live Bacteria

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ABSTRACT

Using specific peptide bacteria affinity, a monolayer of 30 nm Au particle is selectively deposited on live bacteria surface to produce electrically conducting bridges spanning over 12 μ m. The conductivity of the monolayer network is further improved by over 10-fold by "electric-field annealing". The annealing process is explained by a percolation model.



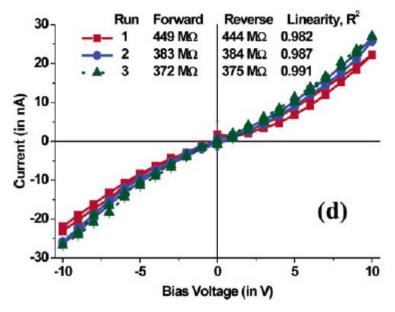


Figure 1. (a), (b) Typical FESEM images showing bacteria coated with Au nanoparticle monolayers and spanning between two Au electrodes at the extreme ends. The size bar is $1\mu m$. (c) The nanoparticle size and monolayer morphology are more evident at higher magnification. The size marker is 300 nm. (d) Typical I-V characteristics of as-received (run #1) and subsequent cycles of a device with 15 bridges between the electrodes. The error bars on each data point are based on 10 points over a time period of 5 s. The resistance is measured by fitting a line through the origin with fitness parameter R^2 . The I-V characteristics become reproducible after the first run.

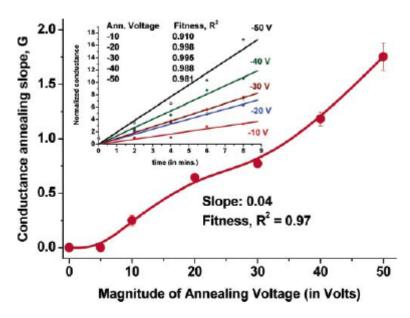


Figure 2. Normalized conductance is defined as R_i/R , where R_i is the resistance at t = 0 (i.e., after the third cycle in Figure 1). All the devices are on the same chip and therefore fabricated under identical conditions. The slope G is in min⁻¹.

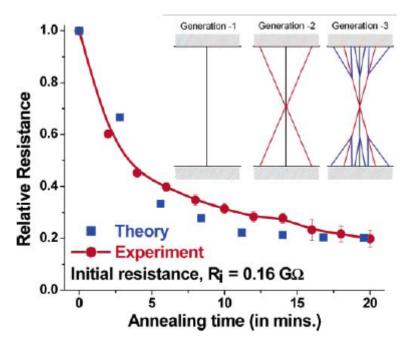


Figure 3. Annealing time versus relative resistance, R/R_i of a sample showing the plateau region after \sim 20 min. The theory points are based on the percolation model for coordination number, f+1=4. Inset shows three generations due to f=3 branching. The channels are drawn as straight lines for simplicity.